



<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  <b>(PTO/SB/O8A)</b>				ATTY. DOCKET NO. 1268-254		U.S. PATENT APPLICATION NO. 10/566,369	
				APPLICANT <b>Oleg NAIGERTSIK et al.</b>			
				FILING DATE January 30, 2006		GROUP	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	Abstract	Translation	Equivalent	
/T.T./	0281034	9/1988	EP				
/T.T./	0581651	2/1994	EP				
/T.T./	0934773	8/1999	EP				
/T.T./	2703927	10/1994	FR				
/T.T./	2774906	8/1999	FR				
/T.T./	2780901	1/2000	FR				
/T.T./	19811900	9/1999	DE				
/T.T./	1319991	6/1973	GB				
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
/T.T./	Aizawa et al., "Preparation of Spherical Hydrous Silica Oxide Particles under Acidic Condition via Sol-Gel Processing," JOURNAL OF SOL-GEL SCIENCE AND TECHNOLOGY 19, 329-332, 2000						
/T.T./	Avnir et al., "Organic Fluorescent Dyes Trapped in Silica and Silica-Titania Thin Films by the Sol-Gel Method Photophysical, Film and Cage Properties," JOURNAL OF NON-CRYSTALLINE SOLIDS 74, (1985), 395-406						
/T.T./	Barbe et al., "Sol-Gel Microspheres and Nanospheres for Controlled Release Applications," Controlled Release Society 29 <sup>th</sup> Annual Meeting Proceedings, #293, 545-546						
/T.T./	Butler et al., "An emulsion method for producing fine, low density, high surface area silica powder from alkoxides," JOURNAL OF MATERIALS SCIENCE 31, (1996), 1675-1680						
/T.T./	Federal Register, Vol. 67, No. 94, 34616-34620						
/T.T./	Hou et al., "Improvement of photofatigue resistance of spirooxazine entrapped in organic-inorganic composite synthesized via the sol-gel process," SPIE, Vol. 2288 Sol-Gel Optics III, (1994), 328-339						
/T.T./	Nakatsuka, "Surface Modification of Inorganic Pigments with Organic UV Absorbers," COLLOIDS AND SURFACES 34, (1988/89), 323-324						
/T.T./	Tatapudy et al., "Benzoyl Peroxide Microcapsules I. Preparation of Core Material," INDIAN DRUGS 32(6), (1995), 239-248						
EXAMINER /Thao Tran/ (04/02/2010)				DATE CONSIDERED 04/02/2010			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /T.T./

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/T.T./	7-238983	9/1995	JP				
/T.T./	9235217	9/1997	JP	X			
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